Surface Layering in Liquid Gallium: An X-Ray Reflectivity Study

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Surface-induced atomic layering in liquid gallium has been observed using x-ray reflectivity, ultrahigh vacuum conditions, and sputtered clean surfaces. Reflectivity data, collected on a supercooled liquid sample to momentum transfers as large as \( q_z = 3.0 \, \text{Å}^{-1} \), exhibit a strong maximum near \( 2.4 \, \text{Å}^{-1} \) indicating a layer spacing that is comparable to its atomic dimensions. The amplitude of the electron density oscillations decays with a characteristic length of 6 Å. This is unexpectedly twice that of recent results for Hg, and the difference may be related to covalent bonding or supercooling.

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The similarity of the bulk structure for both metallic and nonmetallic liquids obscures fundamental differences in the basic physics of the two. The structure of nonmetallic liquids can be understood in terms of classical pairwise interactions; however, for metals, Coulombic interactions couple the quantum electron gas and the classical ions leading to interatomic interactions that strongly depend on density [1,2]. The strong density variation associated with the free surface provides a natural and convenient way of testing this aspect of the theory [3–6]. This was realized early by Rice and co-workers, who proposed to study the surface density profile directly by x-ray reflectivity measurements [3,7]. The problem of surface structure has attracted considerable attention and there are now a number of theoretical, both analytic [4–6] and molecular simulation [8,9], and experimental studies [10–12] of liquid metal surfaces. One of the more interesting ideas generated from these efforts is that partial delocalization of the near surface conduction electrons suppresses positional fluctuations of the near surface ion cores. A direct consequence of this is the prediction of atomic layering at the surface of liquid metals, in contrast to nonmetallic liquids.

The most convenient elements for liquid metal experiments are Ga and Hg, since both are liquid at relatively low temperatures. Earlier experimental efforts to search for surface-induced layering were inconclusive [13,14], and it is only very recently that Magnussen et al. [15] were able to unambiguously demonstrate layering at the surface of liquid Hg. Gallium, on the other hand, exhibits several unique qualities which distinguish it from Hg and most other liquid metals. Perhaps the most striking of these is the asymmetry in the first peak of the bulk liquid structure factor [16], which is not observed in typical liquid metals or Hg and which has been attributed to a relatively high degree of covalent bonding, leading to orientational correlations in bulk liquid Ga [17,18]. This is probably related to other unusual properties of Ga, with respect to most other metals, such as an exceptionally large liquid range (\( \sim 2000 \, ^\circ\text{C} \)), a large crystalline unit cell, and anomalous expansion upon solidification. Competition between the covalent and metallic bonding could explain the observed differences between the surface order for Ga [see Fig. 1(c) below] and that of Hg [15]; however, the microscopic origin of these differences is not yet clear, and, from this point of view, it is critical to understand surface layering for a variety of liquid metals. Finally, in comparison with Hg, Ga has a higher surface tension, leading to mean square thermal fluctuations (capillary waves) in the local height of the surface that are only 70% of that of Hg.

Direct observation of atomic layering requires that specular reflectivity measurements be extended to a wave-vector transfer \( q_z \sim 2\pi/d \sim 2-2.5 \, \text{Å}^{-1} \), where \( d \) is of the order of the atomic diameter, 2.5–3.0 Å. Here we report the results of an x-ray reflectivity study from the liquid Ga surface under ultrahigh vacuum (UHV) which shows the existence of a quasi Bragg peak at \( q_z = 2.4 \, \text{Å}^{-1} \) (Fig. 1). This is a clear indication of surface-induced atomic layering. Although different models can be constructed to agree with the reflectivity data, the unique feature that must be present in each of these is a layered electron-density profile with a surface-induced layer spacing similar to the Ga atomic dimensions and with the layering extending an exponential decay length of \( \sim 3 \) atomic diameters into the bulk [Fig. 1(d)].

The reflectivity data were collected on a shallow supercooled (\( \sim 22 \, ^\circ\text{C} \), melting point at 29.8 \(^\circ\text{C} \)) liquid Ga
The data were collected at the wiggler beam line X-25 at the NSLS using a toroidal mirror and a liquid reflectometer with a water-cooled Ge(111) crystal monochromator set to reflect at $\lambda = 0.6532$ Å. Figure 1(b) illustrates the kinematics of the experiment. The angle of the beam with respect to the horizontal, $\alpha$, was varied by tilting the monochromator, and the position where the beam strikes the sample was varied by adjusting the vertical position of the sample, $s$. For a curved sample surface and a given $\alpha$ ($\delta \alpha = 0.006^\circ$), the local surface normal $\hat{n}(s)$ determines the angle of incidence relative to the surface as well as the angle of reflection $\beta(s)$; the extent of the illuminated area determines the divergence $\delta \beta(s)$ of the reflected beam. Careful mapping of $\beta(s)$ and $\delta \beta(s)$ vs $s$ allows a determination of the local and average sample curvature [14,19].

In Figs. 2(a) and 2(b) we show typical profiles of the reflected beam as a function of $\beta$ (in the plane of reflection) measured for $\alpha = 2.33^\circ$ and $6.9^\circ$. For sufficiently small $\alpha$, the reflected signal is large and easy to separate from the diffuse scattering. For larger $\alpha$, near the peak in the bulk liquid structure factor, the diffuse scattering is considerably larger than the reflected signal; however, they can be separated by making use of their measured line shapes [19]. For a given $\alpha$ and $s$, the reflectivity $R(q_z)$ at $q_z = (4\pi/\lambda) \sin((\alpha + \beta(s))/2)$ is determined by integration over $\beta$ after removal of the diffuse scattering. Comparison of reflected intensities for different $\alpha$, $s$, and $\beta(s)$ established that $R(q_z)$ is insensitive to the precise location of illuminated surface area. With this approach, the reflectivity is obtained by measuring within the plane of reflection; a supplementary mode of measurement entails scanning the detector across the plane of reflection (i.e., a $2\theta$ scan). Examples of $2\theta$ scans [Figs. 2(c) and 2(d)] show the reflected profiles as resolution limited peaks above an essentially constant background.

The reflectivity obtained from analysis of both the $\beta$ and $2\theta$ scans are plotted in Figs. 1(a) and 1(c), and there is good agreement. The importance of in situ surface cleaning is clearly demonstrated by inclusion in the figure of data collected on oxidized Ga surfaces and then on sputtered clean surfaces, as well as during the first $\sim 2$–$3$ h into the sputtering procedure. Also included in Fig. 1(a) are previous measurements from our group for $q_z \leq 0.55$ Å$^{-1}$ [14], the theoretical Fresnel reflectivity ($R_F$) and that expected for a monotonic density profile with the theoretically predicted capillary wave roughness of 0.82 Å. The data obtained on the clean Ga show

![Image](image-url)
no appreciable deviation from Fresnel theory except for
\( q_z > 2.0 \, \text{Å}^{-1} \), where a well-defined maximum is evident.
The marked difference in reflectivity from a dirty surface,
which deviates greatly from \( R_F \) and was not measurable
for \( q_z > 1 \, \text{Å}^{-1} \), and then from a clean one, highlights
the importance of maintaining a UHV-clean, oxide-free
surface for these studies.

When scaled by the Fresnel reflectivity [Fig. 1(c)],
the data are of a rather simple form. The ratio \( R/R_F \)
can be generally described with as few as four parameters in real
space that are equivalent to the amplitude, decay length,
and spacing of the electron density oscillations into
the bulk liquid and the interfacial roughness. Although
a number of density models can be constructed with
additional parameters that lead to even better agreement
with the data, only two of the simplest models will
be mentioned here. Without additional data at \( q_z \geq 3.0 \, \text{Å}^{-1} \),
it is not possible to determine much more than
the basic features of the layering profile.

For \( q_z \) larger than \( 4-5 \) times the critical wave vector,
\( R/R_F \) is related to the average electron density along the
surface normal, \( \langle \rho(z) \rangle \), by [20]

\[
\frac{R(q_z)}{R_F(q_z)} \approx \frac{1}{\rho_\infty} \int \left[ \frac{d\langle \rho(z) \rangle}{dz} \right] e^{iq_z z} dz \left[ \frac{f(q_z)q_z d}{Z} \right]^2 \left| e^{iq_z Z} e^{-iq_z d} - 1 \right|^{-2},
\]

where \( f(q_z) \) is the Ga atomic scattering factor [atomic
dispersion corrections \( f'(q_z) \) and \( f''(q_z) \) are negligible]
and \( Z \) the atomic number. Figure 1(c) shows the best
fit (dashed line) of this model, with \( d = 2.50 \pm 0.01 \, \text{Å}, \)
\( \sigma_0 = 0.67 \pm 0.01 \, \text{Å}, \) and \( \sigma = 0.40 \pm 0.01 \, \text{Å} \).

Analysis with either model leads to essentially the same
results. The interlayer spacing \( d \) is \( \sim 10\% \) less than
the near neighbor spacing in the bulk liquid, which is
expected from the stacking of neighboring layers. For
the second model, in particular, the electron density profile
can be interpreted as a local structure that is broadened
by thermally induced capillary waves, denoted by a
width \( \sigma_{cw} \) [21]. Given the Ga surface tension at the
melting point \( \gamma = 0.718 \, \text{N/m}, \) atomic diameter \( \sim 2.5 \, \text{Å}, \)
and an experimental resolution of \( 0.062 \times 0.0008 q_z \, \text{Å}^{-2} \),
calculated values for \( \sigma_{cw} \) range from 0.75 to 0.90 Å over
the measured \( q_z \) range. These values are in agreement
with the width of the top layer, which in the second model
is given directly by \( \sqrt{\sigma_0^2 + \sigma^2} = 0.78 \, \text{Å} \), and indicate
that the liquid metal surface is extremely flat with no
measurable roughness except for the broadening expected
from capillary wave theory.

The layering extends into the bulk liquid with an
exponential decay length of \( 5.8 \pm 0.4 \, \text{Å} \), which corresponds
and, although the origin of the difference is not
understood, it may result from either a supercooled Ga
sample or basic differences in the surface properties of
interfacial profile (width \( \sigma \) and offset by \( z_0 \)) modulated
by an exponentially decaying sine wave:

\[
\langle \rho(z) \rangle / \rho_\infty = \text{erf}[ (z - z_0) / \sigma ] + \theta(z) \sin(2\pi z / d) e^{-z / \xi}.
\]

\( \theta(z) \) is the step function, \( d \) the interlayer spacing,
\( \xi \) the exponential decay length, and \( A \) an amplitude.
Fits by this model are shown in Fig. 1(c) (solid line),
with \( d = 2.56 \pm 0.01 \, \text{Å}, \) \( \xi = 5.8 \pm 0.4 \, \text{Å}, \)
\( A = 0.20 \pm 0.02, \) \( \sigma = 0.50 \pm 0.04 \, \text{Å}, \) and
\( z_0 = -0.24 \pm 0.06 \, \text{Å} \). The electron density profile
is shown in Fig. 1(d); profiles computed within the errors
of the parameters would be indistinguishable in the figure.

Similar results are obtained with the distorted crystal
model that has been used for liquid Hg [15]. In this
model, the root-mean displacement of the \( n \)th layer,
(\( \sigma_n \), increases with depth into the bulk liquid. To simplify
and limit the number of parameters, let \( \sigma_n^2 = \sigma_0^2 + n\sigma^2 \) with
\( \sigma \) a measure of the increasing root-mean displacement
as the density approaches the bulk liquid and \( \sigma_0 \) a
displacement common to each layer. With the spacing
\( d \) between layers fixed, the reflectivity is

\[
\frac{R(q_z)}{R_F(q_z)} = e^{-q_z^2 \sigma_0^2} \left| \frac{f(q_z)q_z d}{Z} \right|^2 \left| e^{iq_z Z} - 1 \right|^{-2},
\]

FIG. 2. Scans of intensity in the plane of reflection (scan \( \beta \);
\( 2\theta = 0 \)) for (a) \( \alpha = 2.33^\circ \) \( (q_z = 0.782 \, \text{Å}^{-1}) \) and (b) \( \alpha = 6.9^\circ \)
\( (q_z = 2.48 \, \text{Å}^{-1}) \). Dashed lines are fits to the diffuse scattering,
and solid lines are fits to the reflection superimposed on the
diffuse scattering. Corresponding scans through the plane of
reflection (scan \( 2\theta \); \( \beta \) set at the specular reflection), for (c)
\( \alpha = 2.33^\circ \) and (d) \( \alpha = 6.9^\circ \), illustrate a second method to
distinguish the reflection. To compensate for the decrease in
reflectivity for \( \alpha = 6.9^\circ \), the height of the incident beam was
approximately \( 2 \times \) greater than for \( \alpha = 2.33^\circ \). The horizontal
detector resolution was set at 0.4° in (c) and 0.1° in (d).
Confidence limits for these fits are included in the error bars
shown in Fig. 1.
liquid Ga and Hg, which are, for example, manifested by the much smaller vapor pressure and larger surface tension of Ga. Another possibility is the idea mentioned earlier about the importance of different orientational correlations in the near neighbor packing around individual Ga and Hg atoms.

Furthermore, unlike Hg, the decay in layering amplitude for Ga is not well characterized by the decay present in its bulk pair correlation function. Since the correspondence for Hg was taken to indicate that the layering is dominated essentially by the same isotropic short-range effective interactions which determine the bulk packing [15], its absence here may be related to other interactions at the Ga surface, e.g., bond correlations, which are possibly more dominant in the near surface region. Another subtle difference between the Ga and Hg results is that, at the Ga surface, e.g., bond correlations, which are possibly more dominant in the near surface region. Another subtle difference between the Ga and Hg results is that, in agreement with the Ga simulations [9], we find no evidence for the broad tail on the vapor side of the interface which was experimentally observed [15] and predicted by simulations [22] for the surface of Hg. Finally, we note that our results are in agreement with computer simulations on Ga, which predict a similarly layered profile that extends ~3 atomic diameters into the bulk [9].

The excess lamellar order that is observed here is likely related to the excess order on the liquid side of the liquid/crystal interface that Turnbull [23] and, more recently, Spaepen [24] have discussed in connection with the supercooling of liquid metals. It is, therefore, worth comparing the two phenomena. One important issue is the amount by which surface-induced lamellar order may possibly be supplemented by in-plane positional order (i.e., in the surface plane). It is not clear whether lamellar order alone can fully account for the negative surface entropy at the liquid/crystal interface, since the crystal lattice may induce in-plane order in the liquid. At the Ga liquid/vapor interface, computer simulations and grazing-incidence x-ray experiments indicate that the in-plane structure is similar to the bulk liquid without any obvious positional order [25], although this needs to be investigated further. The subject is also closely related to premelting phenomena in which certain crystalline facets exhibit excess disorder at the liquid/crystal interface, leading to a positive surface entropy. Although it is important to understand the microscopic origin of these differences and there have been major efforts to understand, for example, the theory of premelting [26], structural data on the excess order at liquid interfaces mentioned remain also nonexistent.

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